	บ	1	Docu	ument ID	Issue Date	Pages	Title	Current	OR
1	×		JP 1 A	1340229	19991210	10	COPPER INTERCONNECTION OF METAL SEED LAYER INSERTION STRUCTURE		
2			EP 9	954027 A	20020531	10	Interconnect structure for a semiconductor device		

	Current XRef	Retrieval Classif	Inventor	s	С	P	2	3	4	5
1			EDELSTEIN, DANIEL CHARLES et al.							
2			EDELSTEIN, D C et al.	×						

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1	JP	11340229 A			
2	US	6181012			